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CHEMICAL PROCESS CONTROL—

CPCIV, 1991, edited by Yaman Arkun, Georgia Institute of Technology, and W. Harmon Ray, University of Wisconsin.

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AIChE Journal (ISSN 0001-1541) is published monthly by the American Institute of Chemical Engineers, 345 E. 47th St., New York, NY 10017. Manuscripts should be submitted to Editor Matthew V. Tirrell at the Dept. of Chemical Engineering and Materials Science, University of Minnesota, Minneapolis, MN 55455, phone (612) 625-5823, fax (612) 626-1686. The statements and opinions in the *AIChE Journal* are those of the contributors, and AIChE assumes no responsibility for them. Annual subscription rates: \$384 for nonmembers, \$60 for members, and \$30 for student members; outside U.S., add \$34 for postage. Single copies: \$38; outside U.S., add \$3 for postage. Second-class postage paid at New York, NY and additional mailing offices. Copyright 1993 by the American Institute of Chemical Engineers. Subscribers are requested to give prompt notification of any change of address. Postmaster: Send changes of address to *AIChE Journal*, 345 East 47th St., New York, NY 10017.

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